

FIG 1: PLASMA SPUTTER DEPOSITION SYSTEM

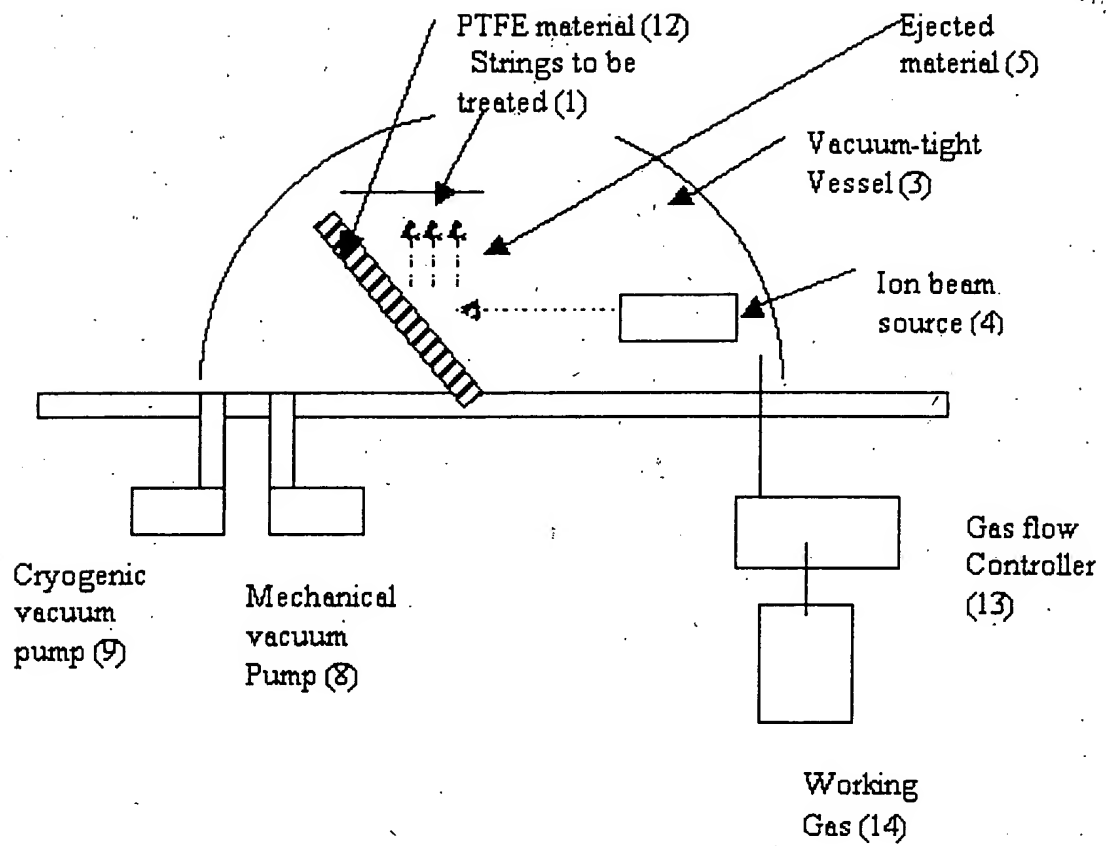


FIG 2: ION BEAM DEPOSITION SYSTEM

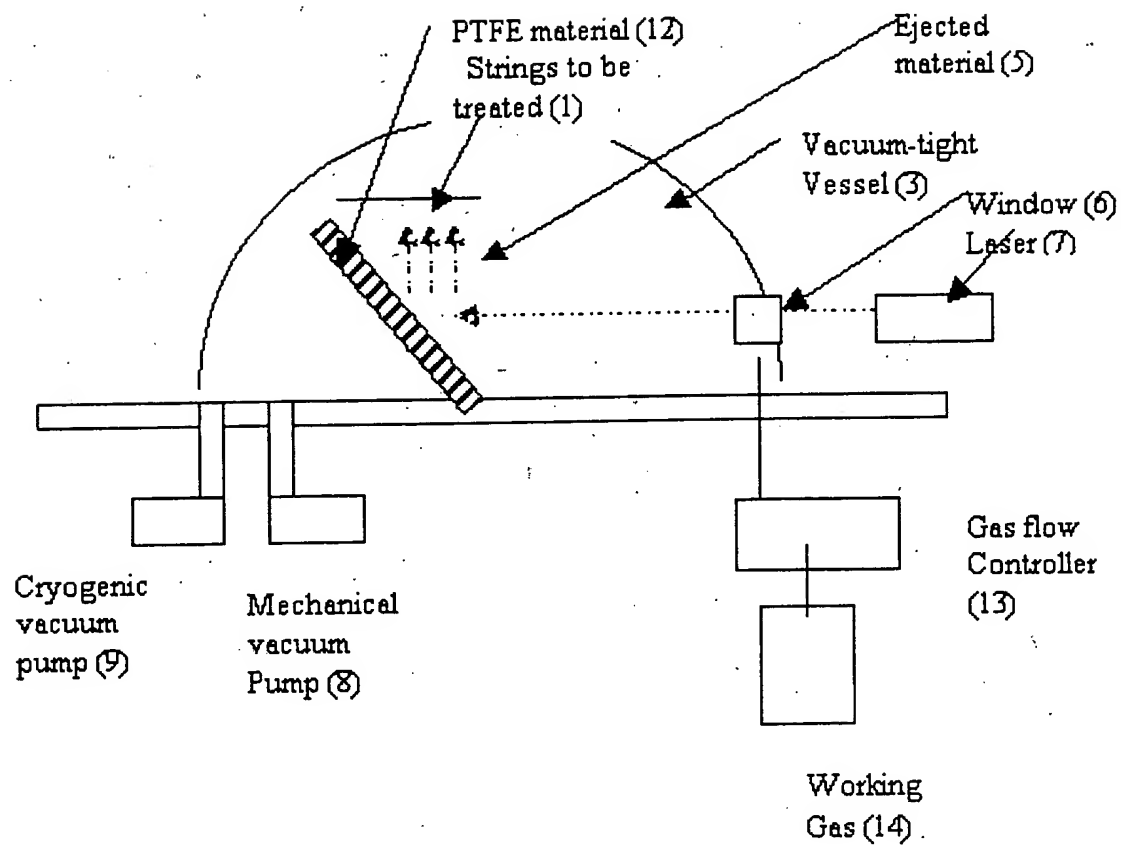


FIG 3: LASER DEPOSITION SYSTEM

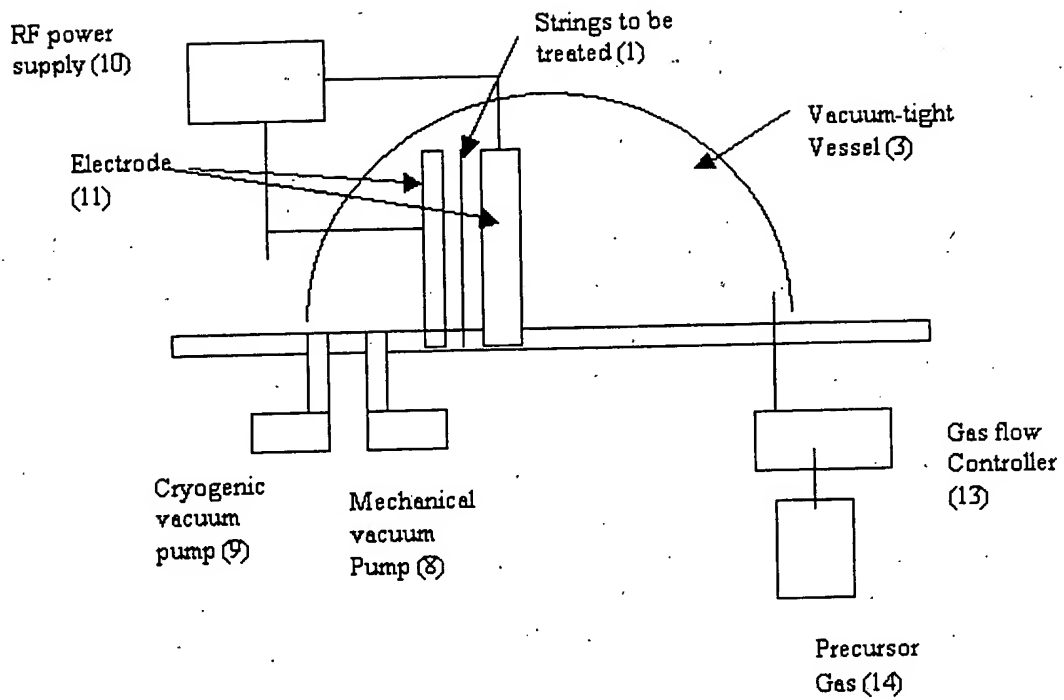


FIG 4: PLASMA CHEMICAL VAPOR DEPOSITION SYSTEM

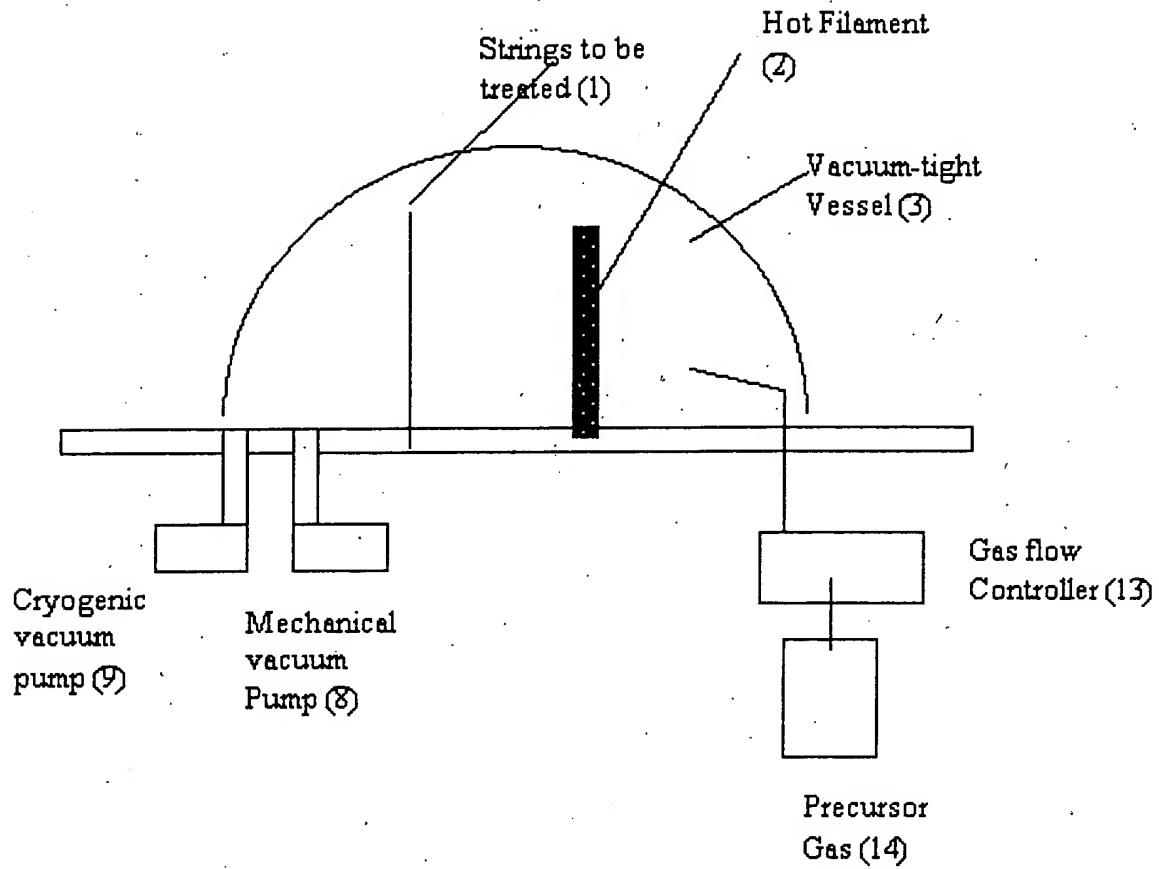


FIG 5: HOT FILAMENT CHEMICAL VAPOR DEPOSITION SYSTEM

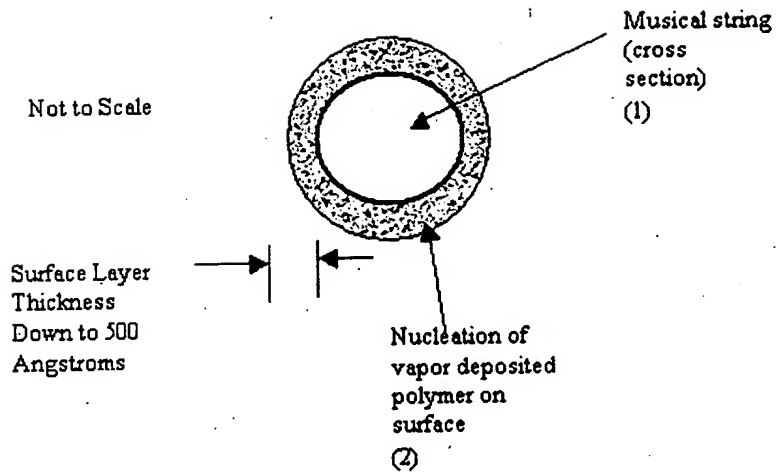
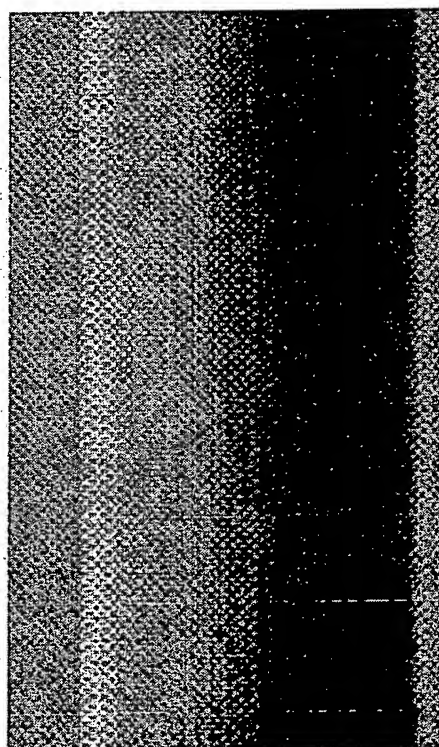
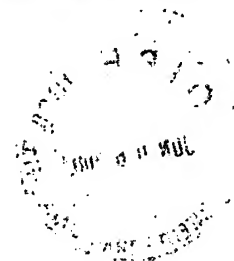


FIGURE 6: MUSICAL STRING TREATED WITH VAPOR DEPOSITED POLYMER



*FIGURE 7*

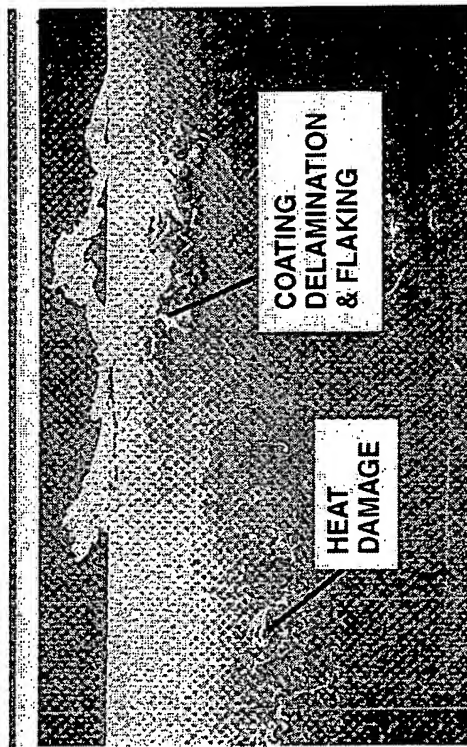


FIGURE 8



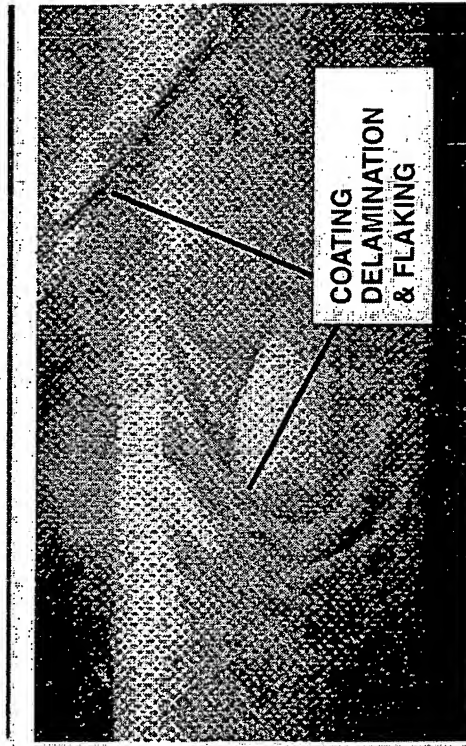
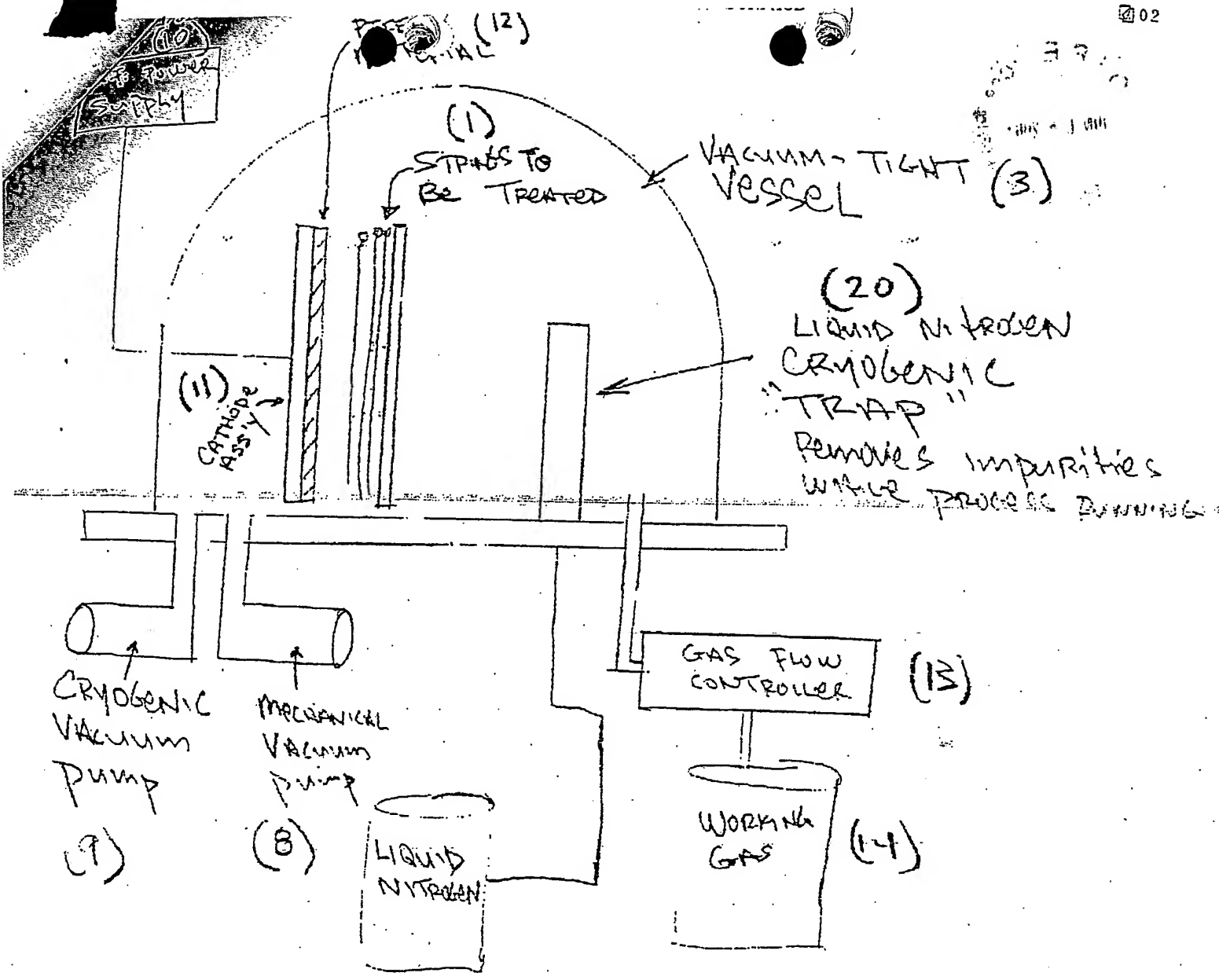
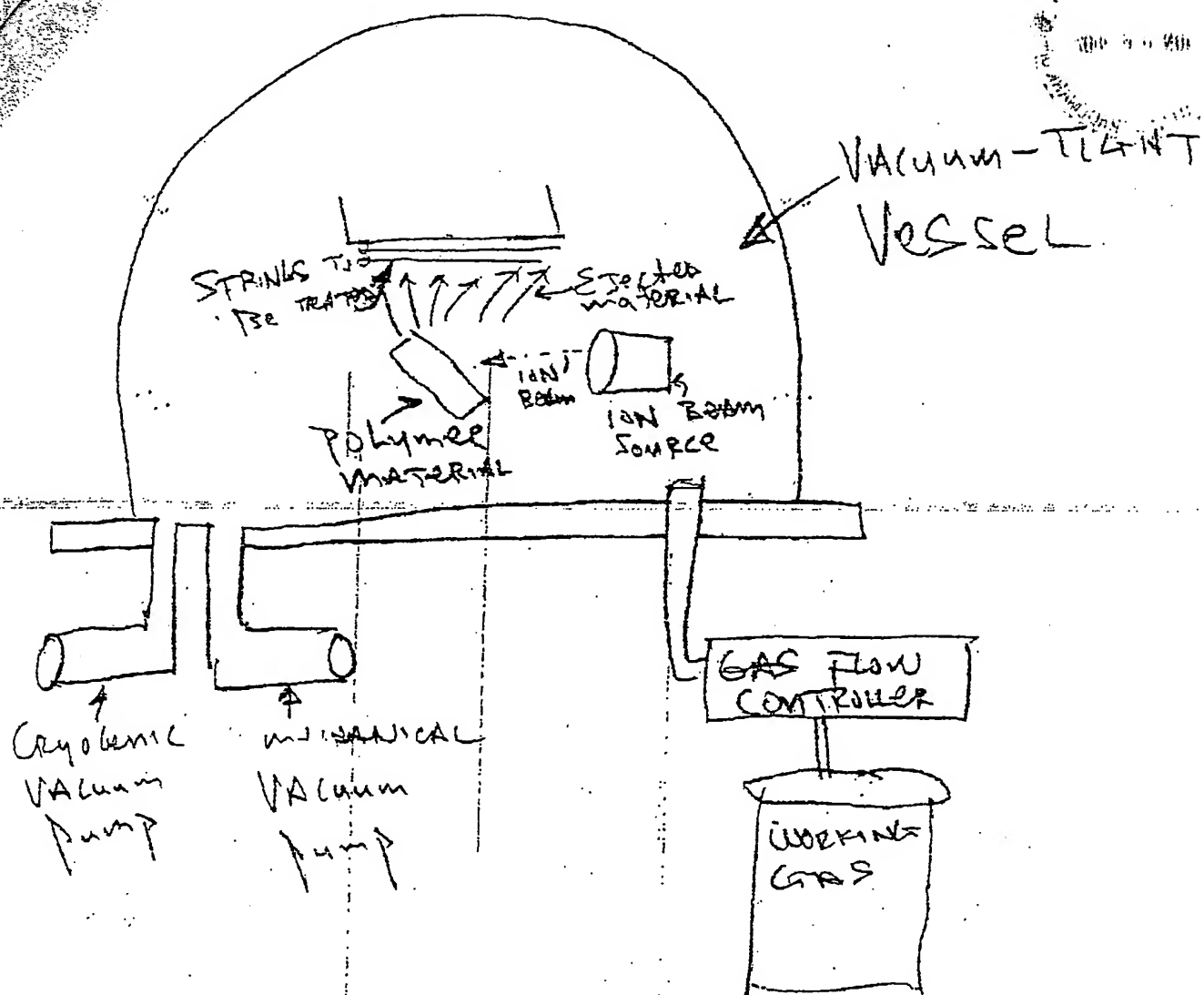


FIGURE 9



# PLASMA SPUTTER DEPOSITION

Fig. 1



ION BEAM SPATTERING

FIG. 2

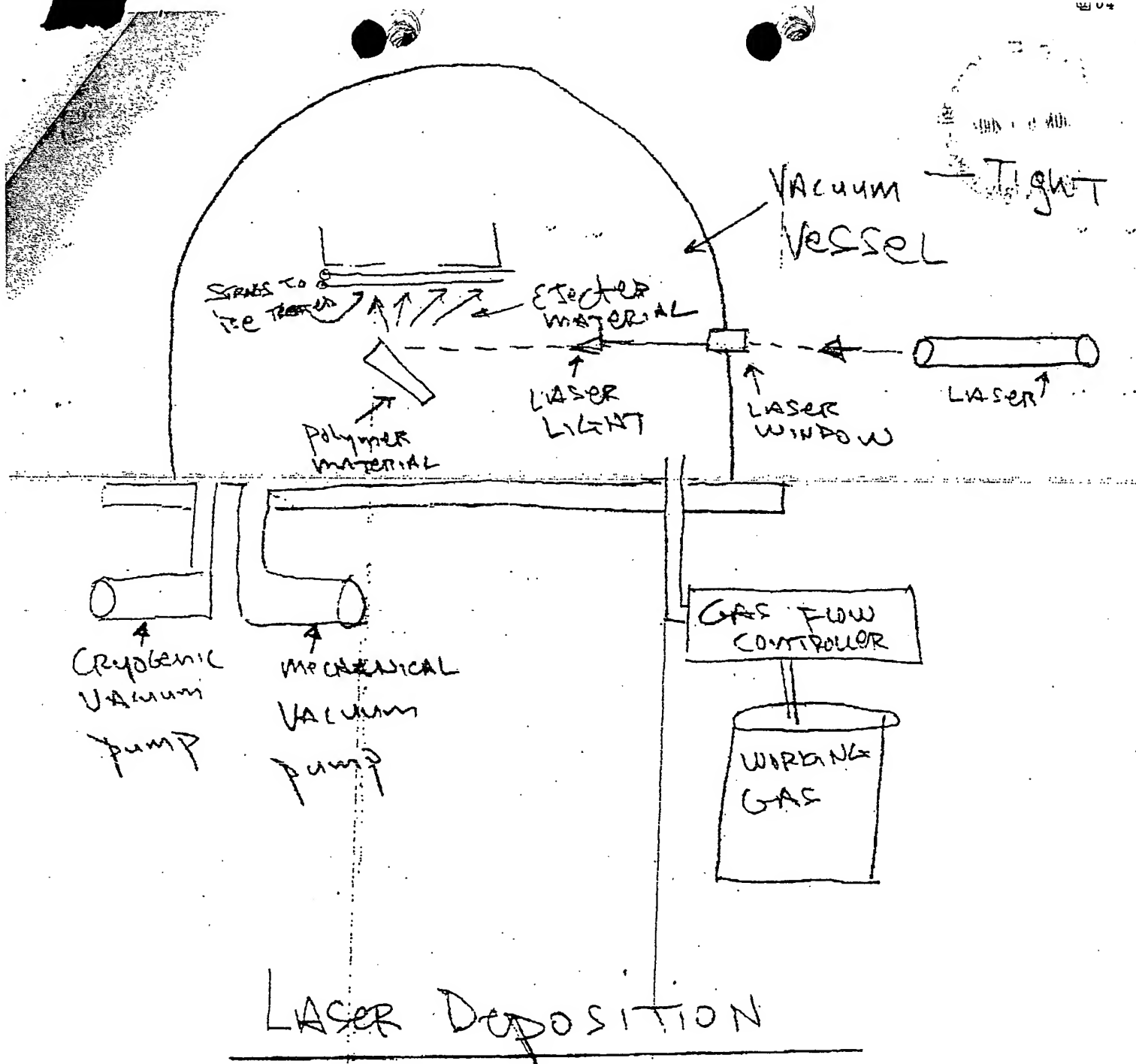
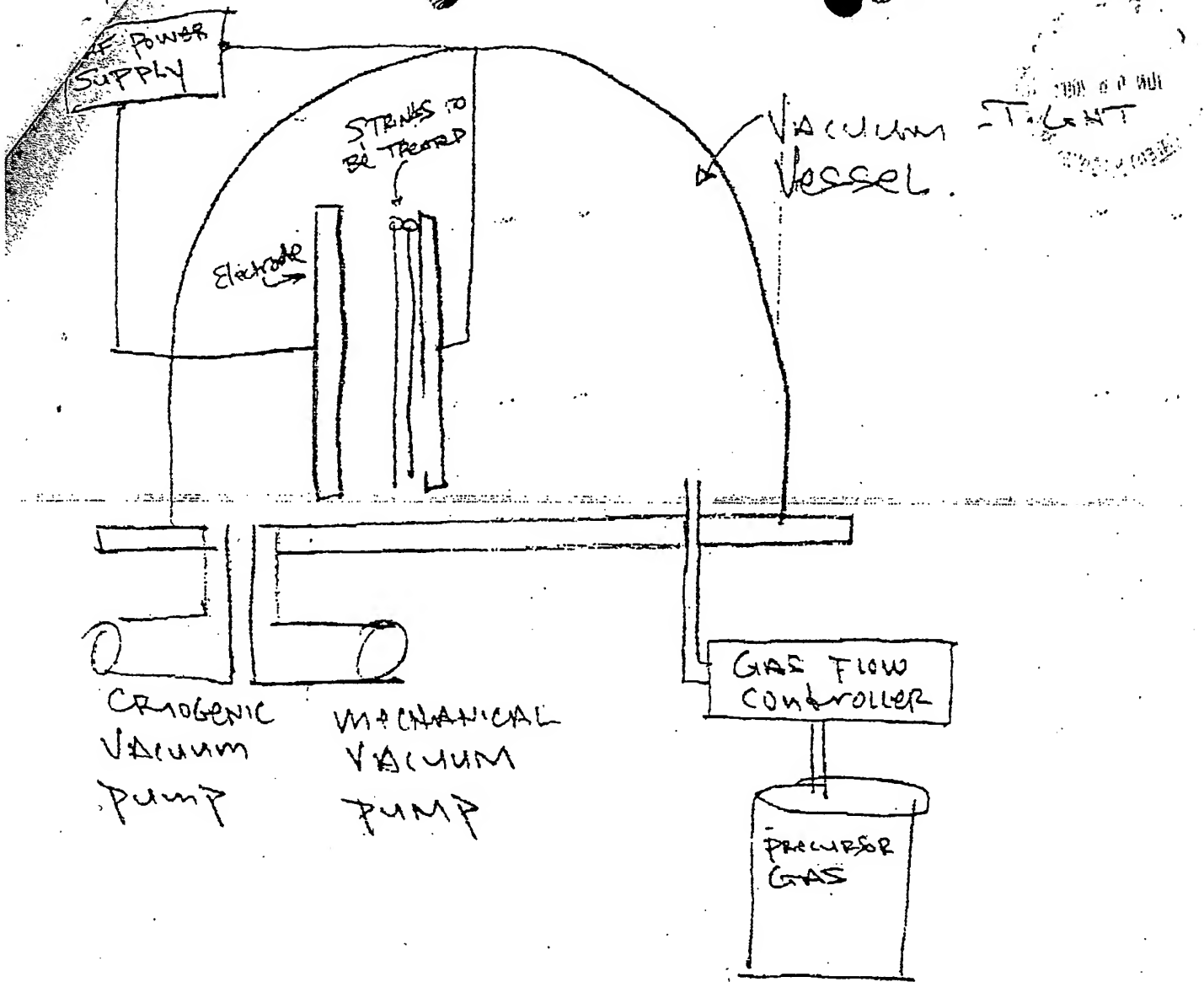
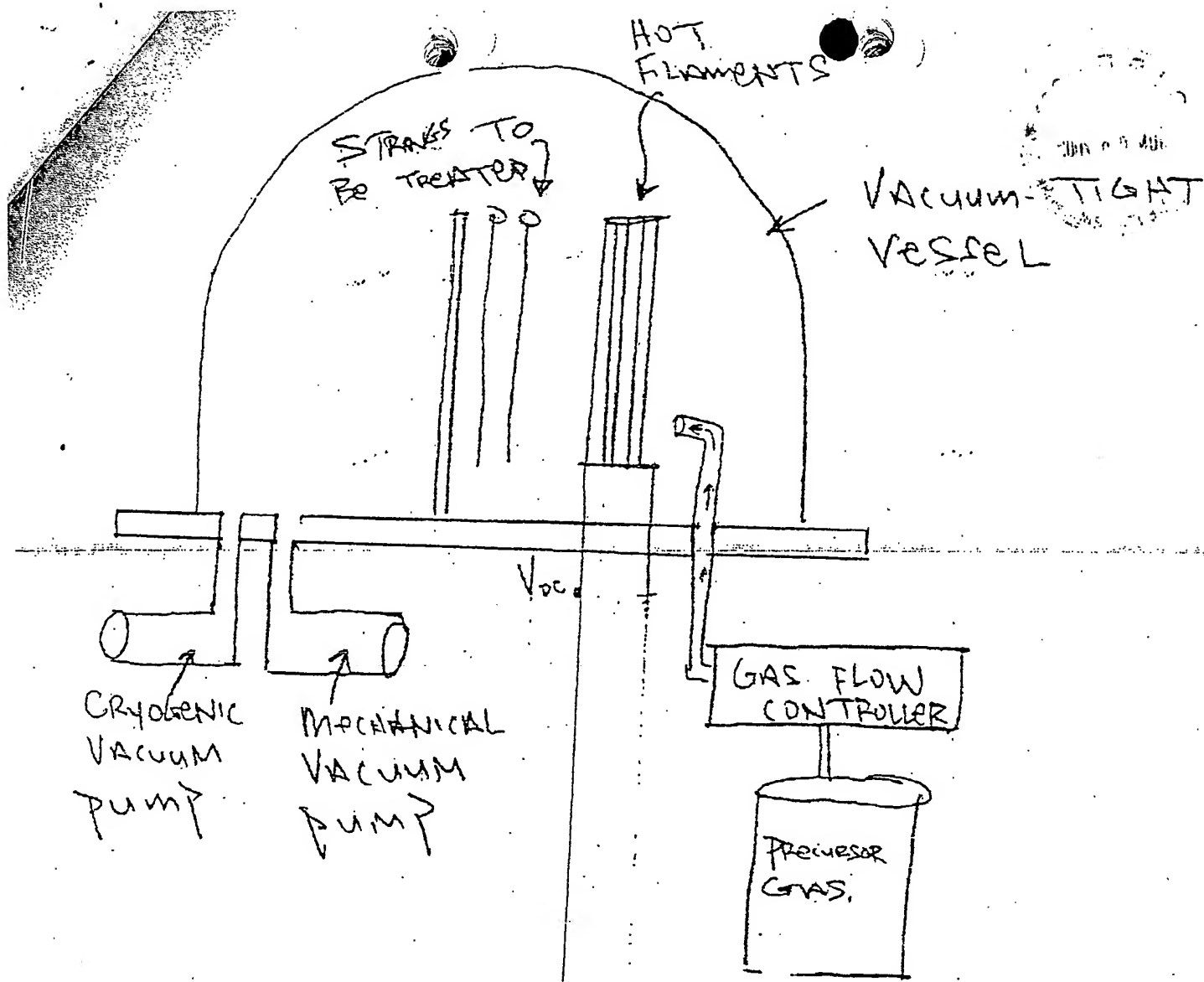


FIG 3



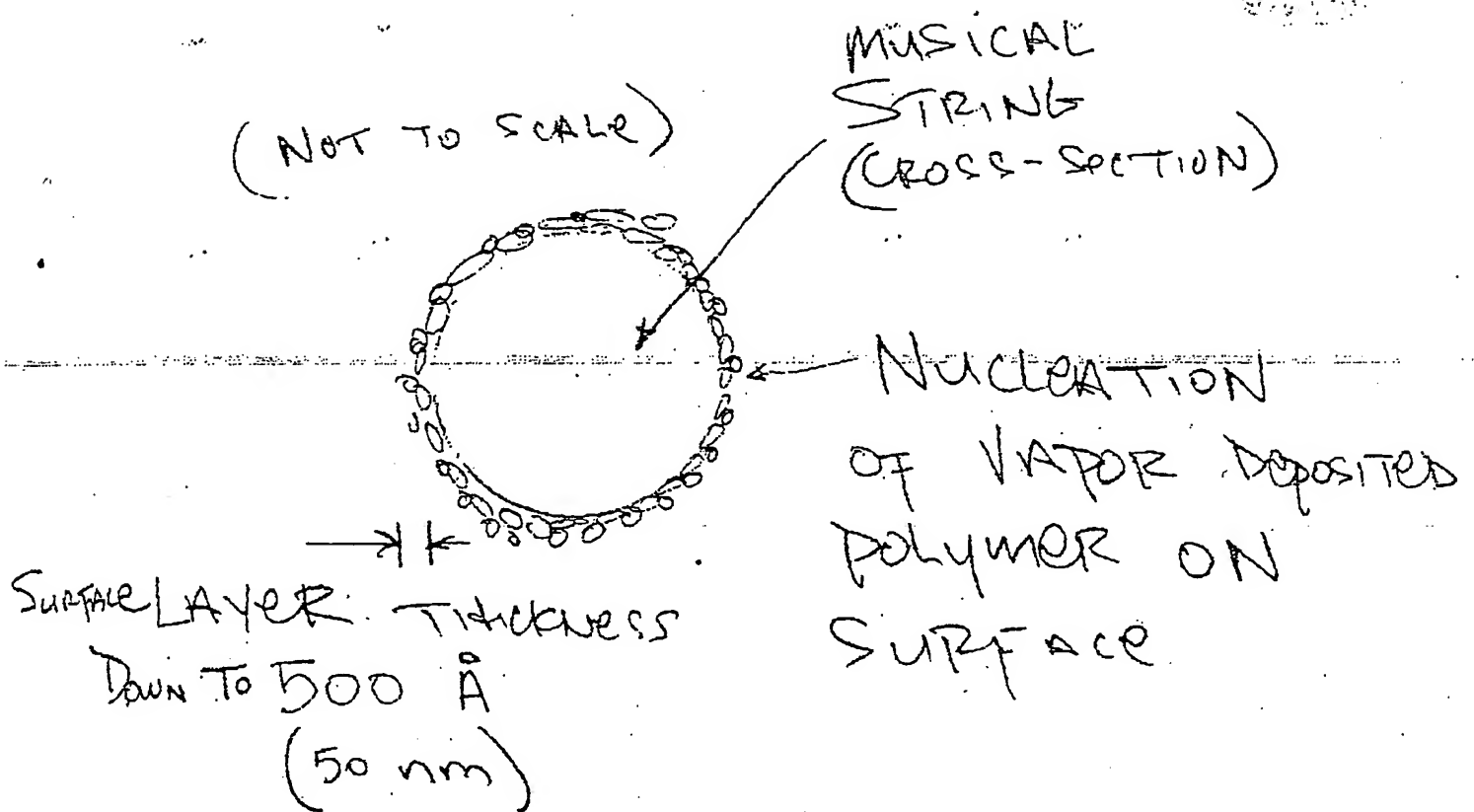
# PLASMA CHEMICAL VAPOR DEPOSITION

FIG. 4



# HOT FILAMENT CHEMICAL VAPOR DEPOSITION

Fig 5



MUSICAL INSTRUMENT STRING TREATED  
W/ VAPOR DEPOSITED POLYMER  
NUCLEATE

FIG 6

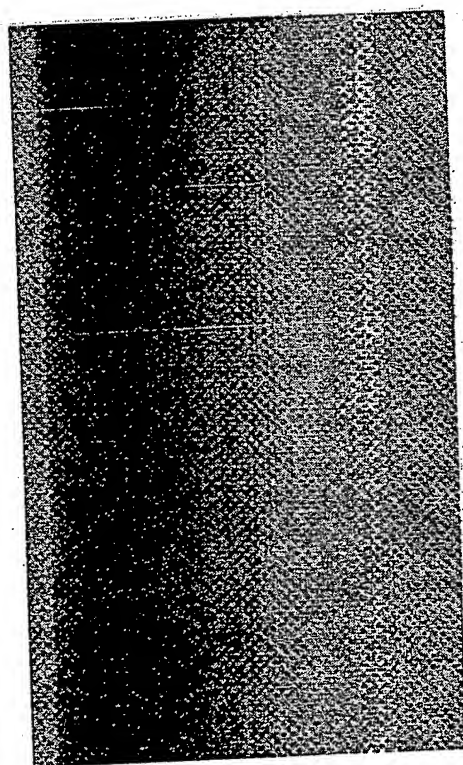


FIG 7



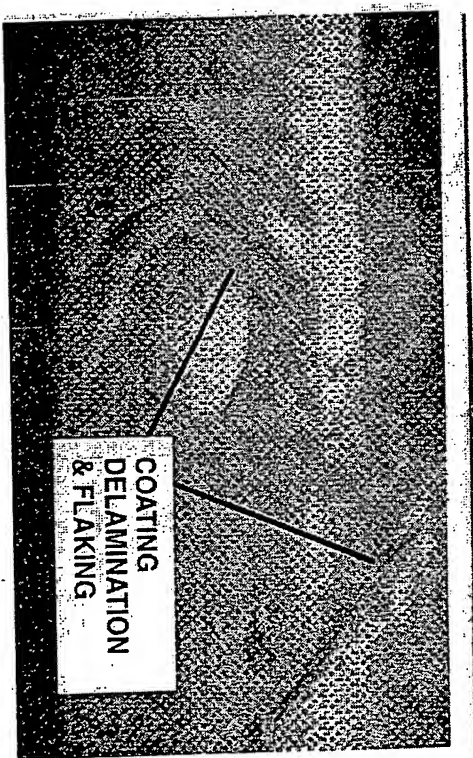
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Fig 8



FIG 9



Substitute drawings (9)

